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Enhanced osseointegration of hierarchically structured Ti implant with electrically bioactive SnO$_2$-TiO$_2$ bi-layered surface

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KEYWORDS: Hierarchical structure, Electrical bioactivity, SnO$_2$-TiO$_2$, Ti implant, osseointegration.

ABSTRACT: The poor osseointegration of Ti implant significantly compromise its application in load-bearing bone repair and replacement. Electrically bioactive coating inspired from heterojunction on Ti implant can benefit osseointegration but cannot avoid the stress shielding effect between bone and implant. To resolve this conflict, hierarchically structured Ti implant
with electrically bioactive SnO$_2$-TiO$_2$ bi-layered surface has been developed to enhance osseointegration. Benefiting from the electric cue offered by the built-in electrical field of SnO$_2$-TiO$_2$ heterojunction and the topographic cue provided by the hierarchical surface structure to bone regeneration, the osteoblastic function of basic multicellular units (BMUs) around the implant is significantly improved. Because the individual TiO$_2$ or SnO$_2$ coating with uniform surface exhibits no electrical bioactivity, the effects of electric and topographic cues to osseointegration have been decoupled via the analysis of in vivo performance for the placed Ti implant with different surfaces. The developed Ti implant shows significantly improved osseointegration with excellent bone-implant contact, improved mineralization of extracellular matrix (ECM), and increased push-out force. These results suggest that the synergistic strategy of combing electrical bioactivity with hierarchical surface structure provides a new platform for developing advanced endosseous implants.

**INTRODUCTION**

Ti metal has gained worldwide recognition as one of the most acceptable candidates for load-bearing bone repair materials. However, the osseointegration of Ti implants is often compromised due to the stress shielding effect and its bio-inertness. In particular, the lack of mechanical stimulation to bone caused by the stress shielding effect and the poor bone-implant bonding due to the generation of soft tissue on bio-inert pure Ti surface would directly lead to the osteoporosis around the implantation site. Consequently, it eventually results in the failure of the implant. As a living tissue, bone can remodel itself around the implantation site to adapt to the
new mechanical environment based on the structure of placed implant. This process is accomplished by assembly of osteoblasts and osteoclasts into functional units, named as basic multicellular units (BMUs). Because the implant surface directly touches with the surrounding environment after surgery, the behavior of cells in the BMUs could be mediated by the surface of implant. Thus, great efforts have been devoted to modifying the structure and surface of Ti implant for improving osseointegration.

Depending on the mechanical properties of composite material, the gradient stress distribution corresponding to hierarchically porous surface of implant with bone tissue could alleviate the stress shielding effect. To obtain the interlocking effect between the implant and bone tissue, the size of gouges on the implant surface should be larger than 50 µm, which can provide enough space for bone ingrowth based on the osseoconduction. The fabrication of hierarchically porous surface with excellent bonding to Ti implant is key to ensure the success of the implant in load-bearing bone repair. Fortunately, the porous surface of TiO₂ coating formed by microarc oxidation (MAO) can be regulated by controlling applied parameter, and the as-formed coating exhibits excellent bonding with Ti substrate. Therefore, a multi-scale porous TiO₂ surface with micro gouges and sub-micro pores has been developed on Ti implant via MAO, which enhances mechanical stimulation for improving osseointegration based on the topographic cue from hierarchically structured surface to transmit load. Though the Ti implant with certain hierarchical surface structure exhibits an enhancement in push-out force, soft tissue is still partially covered the implant due to the poor bioactivity of the surface.

In order to achieve a good osseointegration after implantation, numerous strategies have
been developed to facilitate Ti surface with good bioactivity. \textsuperscript{15-20} Though chemical and topographical-based coatings are the most promising approaches to render Ti surface with excellent \textit{in vivo} performance, \textsuperscript{17-19} their effects to bone tissue around the implantation site are still limited if they have indirect contact with implant surface. Considering the stress shielding effect, osteoporosis would easily occur in certain areas. It is known that bone is a piezoelectric material, in which electric cue offered by externally applied electrical fields can modulate osteoblastic cell behavior. \textsuperscript{21,22} Since the bone tissue can conduct electrical signal, the electric cue could not only affect the contact interface but also influence the indirectly-contacted surrounding area of the implant. However, electric cue provided by an external equipment is impractical for orthopedic implant application. \textsuperscript{23} To realize such a concept, developing Ti implant with an internally built-in electrical field would be critical for the next-generation of implant. \textsuperscript{23-25}

A promising strategy for the fabrication of such an internally built-in electrical field is based on the concept of heterojunction, which promotes the separation of hole-electron pairs. \textsuperscript{25-27} Meanwhile, because of the electric coupling among different electrical fields, \textsuperscript{28} the heterojunction with the built-in electrical field can continuously provide electric cue to ensure a long-term effect of the electrical bioactivity based on the response to varied electrical field from piezoelectric bone during movement. \textsuperscript{29} Interestingly, a built-in electrical field on smooth Ti plate via the formation of bi-layered SnO$_2$-TiO$_2$ heterojunction with type II band alignment was reported in our previous work, which exhibited superhydrophilicity and good apatite-forming ability. \textsuperscript{30} To render the hierarchically porous Ti implant with excellent bioactivity, in this work, the bi-layered SnO$_2$-TiO$_2$ heterojunction was fabricated on the surface of hierarchically
structured Ti implant by MAO and subsequent hydrothermal treatment.

Because the individual TiO$_2$ or SnO$_2$ coating with an uniform surface does not exhibit bioactivity induced by electric cue, it provides a platform to decouple the effects of electric cue and topographic cue to osseointegration via the comparison of the bone remodeling, bone-implant interface, and biomechanical property for the prepared Ti implants with different surface structures.

RESULTS AND DISCUSSION

Figure 1 Surface morphologies of modified Ti implants with different structures: a) Ti, b) Ti-TiO$_2$, c) Ti-TiO$_2$-SnO$_2$; flat area of d) R-Ti, e) R-Ti-TiO$_2$, f) R-Ti-TiO$_2$-SnO$_2$; and gouge area of g) R-Ti, h) R-Ti-TiO$_2$, i) R-Ti-TiO$_2$-SnO$_2$.

To ensure a uniform structure of the developed coating at the different areas (flat area and
gouges area) of the implant, the Ti implant surface with micro gouges has been acidly etched to remove the non-uniform oxide film before subsequent treatments. The reason for the acid etching is that the non-uniform oxide film would lead to changes in morphology and phase composition of the as-formed MAO coating in the different areas according to our previous investigation.\textsuperscript{31}

As shown in Figure 1, the surface with a morphology of acidly etched pits has been formed on the surface of rough Ti implant in both flat and gouge area. According to the EDS results, there is no oxide film left on the implant surface (Figure S1). Therefore, the reaction during the subsequent MAO treatment to the implant could occur homogeneously in both flat and gouge areas, retaining to uniform surface morphology on the whole surface. A sub-micro porous layer after MAO treatment (Figure 1(b,e,h)) and a layer of nanorod array after hydrothermal treatment (Figure 1(i) and S2) are observed. In the following, the implants are labeled according to their structure as shown in Table S1, which is divided into two groups, smooth group (Ti, Ti-TiO\textsubscript{2}, Ti-TiO\textsubscript{2}-SnO\textsubscript{2}) and rough group (R-Ti, R-Ti-TiO\textsubscript{2}, R-Ti-TiO\textsubscript{2}-SnO\textsubscript{2}), based on the different surface structures. Owing to the generation of gouges on the rough implant, a mass loss of the implants has been measured, showing the porosity of the rough implants is 18.2 ± 0.2% (Figure S3).
Figure 2  a) XRD patterns of Ti, Ti-TiO\textsubscript{2} and Ti-TiO\textsubscript{2}-SnO\textsubscript{2}; b) Raman spectra of coated implants detected from different area: i) Ti-TiO\textsubscript{2}, ii) flat area of R-Ti-TiO\textsubscript{2}, iii) gouge area of R-Ti-TiO\textsubscript{2}, iv) Ti-TiO\textsubscript{2}-SnO\textsubscript{2}, v) flat area of R-Ti-TiO\textsubscript{2}-SnO\textsubscript{2}, and vi) gouge area of R-Ti-TiO\textsubscript{2}-SnO\textsubscript{2}.

Regarding the heterojunction, the crystallinity of designed phase is the key to its performance.\textsuperscript{32-34} The amorphous MAO coating with SnO\textsubscript{2} film cannot form a heterojunction with electrically stimulated bioactivity because it cannot obtain a stable Fermi energy of TiO\textsubscript{2} to promote the separation of hole-electron pairs.\textsuperscript{30} To meet the formation requirement of heterojunction with type II aligned structure,\textsuperscript{35,36} a high voltage had to be applied to fabricate the MAO coating with good crystallinity. As expected, TiO\textsubscript{2} based MAO coating and the SnO\textsubscript{2} film were formed on Ti substrate after the subsequent treatments as indicated in the XRD patterns (Figure 2(a)).

To further confirm the phase composition of the coating generated on the implant with micro gouges, Raman spectroscopy has been employed to characterize the coating in both gouges area and flat area. Consistent with the XRD results, similar Raman spectra of the MAO coating with two different phases of TiO\textsubscript{2} have been detected from different areas of Ti-TiO\textsubscript{2} and R-Ti-TiO\textsubscript{2},
revealing that the gouge does not affect the phase composition of MAO coating (Figure 2(b)).

The Raman modes centered at 144, 399, 519 and 639 cm$^{-1}$ are pointed to the anatase phase TiO$_2$, while the Raman modes centered at 240, 446 and 609 cm$^{-1}$ are assigned to the rutile phase TiO$_2$. As for the nanorods film, Raman spectra detected from both the gouge and flat areas show similar characteristic vibration modes of SnO$_2$, which are centered at 629 and 689 cm$^{-1}$, respectively (see in Figure S4). Both the XRD and Raman results indicate a uniform SnO$_2$-TiO$_2$ bi-layer was fabricated on the surface of Ti-TiO$_2$-SnO$_2$ and R-Ti-TiO$_2$-SnO$_2$, which is in good agreement with the bi-layered SnO$_2$-TiO$_2$ coating on Ti plate reported in our previous work.

Figure 3 a) the TEM morphology of the powder collected from R-Ti-TiO$_2$-SnO$_2$, b) high resolution TEM morphology of nanorod and c) selected area electron diffraction pattern obtained by Fast Fourier Transform technique from the white box area.

To further confirm the structure of SnO$_2$-TiO$_2$ coating formed on the R-Ti-TiO$_2$-SnO$_2$, TEM
has been used to analyze the powder collected from its surface (Figure 3). Clearly, the nanorod is
mainly composed of Sn and O as confirmed by the EDS results. The selected area electron
diffraction (SAED) pattern of the nanorod obtained by the Fast Fourier Transform (FFT)
technique further confirms its phase of SnO₂ (Figure 3 (c)). Thus, we can confirm that SnO₂
nanorods film was generated on the R-Ti-TiO₂-SnO₂ surface.

Figure 4 a) UV-vis absorption spectra of Ti-TiO₂, Ti-SnO₂, and Ti-TiO₂-SnO₂, b) LSV curves of Ti-TiO₂, and
Ti-TiO₂-SnO₂, c) schematic diagram for the built-in electrical field of SnO₂-TiO₂ heterojunction, and the plots
of (ahv)² versus hv of d) Ti-TiO₂, e) Ti-SnO₂, f) Ti-TiO₂-SnO₂.

Due to the similar phase composition and structure of the bi-layered SnO₂-TiO₂ coating with
our previous work on Ti plate, an n-n heterojunction could be formed on the R-Ti-TiO₂-SnO₂
surface. To confirm the formation of the SnO₂-TiO₂ heterojunction, the band gap of the
bi-layered SnO$_2$-TiO$_2$ coating has been determined by UV-vis spectrophotometer using Ultra Violet Diffuse Reflectance Spectroscopy technique (Figure 4). Based on the UV absorption spectral data, the direct band gaps can be obtained by Tauc relation with a linear fit via the equation:  

$$ \left( \alpha h\nu \right)^2 = A \cdot (h\nu - E_g), $$

where $\alpha$ is absorption coefficient, $A$ is the proportionality constant, $h\nu$ is the photon energy, and $E_g$ is the energy band gap. Clearly, individual TiO$_2$ or SnO$_2$ film shows typical semi-conductor feature, with the calculated band gap of 3.01 and 3.38 eV, respectively. As for the Ti-TiO$_2$-SnO$_2$, the band gaps of both TiO$_2$ layer and SnO$_2$ layer are observed, indicating the formation of SnO$_2$-TiO$_2$ heterojunction. Interestingly, two peaks around 700 and 510 nm are also observed in the UV-vis absorption spectrum of Ti-TiO$_2$-SnO$_2$ (Figure 4(a)), indicating that electrons on Ti-TiO$_2$-SnO$_2$ surface can transfer to conduction band (CB) with lower excited energy than that of individual TiO$_2$ or SnO$_2$. This result further confirms the formation of SnO$_2$-TiO$_2$ heterojunction, because the separated electrons and holes with the metastable status have already been stimulated by the built-in electrical field of heterojunction, resulting in the reduced energy for photoelectronic excitation to overcome the energy barrier. In addition, according to Figure 4(b), the Linear sweep voltammetry (LSV) curve of the Ti-TiO$_2$-SnO$_2$ coating shows significantly larger response current than that of the Ti-TiO$_2$, suggesting better electrical conductivity of the coating due to the formation of heterojunction thus higher charge carrier density. Such SnO$_2$-TiO$_2$ coating exhibits superhydrophilicity, good apatite-forming ability, and negative surface potential, leading to good electrical bioactivity. Combined with the hierarchical structure of Ti implant, the synergistic effect of hierarchical surface structure and electrical bioactivity for the developed Ti implants on osseointegration has
been investigated.

Normally, bone is considered as a dynamic living tissue which is constantly being remodeled throughout its lifetime, it can adapt its mass and architecture to mechanical demands according to the Wolff’s law. To evaluate the status of bone remodeling around the placed Ti implants with different surface structure, the biological tissue around the implants in the region of interest (ROI) ($\Phi 3 \times L 6 \text{ mm}^3$) have been analyzed by micro-CT after healing for 12 weeks.
Figure 5 Micro-CT analysis of the biological tissue around implants after surgery for 12 weeks: micro-CT images of a) Ti, b) Ti-TiO₂, c) Ti-TiO₂-SnO₂, d) R-Ti, e) R-Ti-TiO₂, f) R-Ti-TiO₂-SnO₂, and g) the morphometric results in the ROI. *p < 0.05 compared to the Ti implant, #p < 0.05 compared to the Ti-TiO₂, ^p
< 0.05 compared to the Ti-TiO$_2$-SnO$_2$, &p < 0.05 compared to the R-Ti, &p < 0.05 compared to the R-Ti-TiO$_2$.

According to the cross-sectional morphology of the reconstructed micro-CT images, the biological tissue exhibits a trend to grow along the implant surface towards the marrow cavity (Figure 5). Meanwhile, the biological tissue-implant interface of both the smooth and rough groups shows a similar status with the varied surface structures (the indirect contact for Ti and R-Ti, the partial direct contact for Ti-TiO$_2$ and R-Ti-TiO$_2$, and the almost prefect direct contact for Ti-TiO$_2$-SnO$_2$ and R-Ti-TiO$_2$-SnO$_2$). As for the Ti and R-Ti implants, they are separated from the biologic tissue by gaps due to the bio-inert nature of pure Ti, leading to the indirect contact with bone. Therefore, they both show the least amount of remodeling biological tissue around the implant (Figure 5(a,d)). With regard to the Ti-TiO$_2$ and R-Ti-TiO$_2$, the biological tissue partially contacts with the implant surface, while cavities also appear in the bone near certain area (Figure 5(b,e)). The formation of the cavities could be attributed to the stress shielding effect between the implant and bone, which stimulates osteoclasts to resorb more bone in the decreased levels of stress direction. However, owing to the relatively better bioactivity of TiO$_2$ coating than that of pure Ti, new biological tissue has been generated toward the direction of marrow cavity around the implant to ensure load bearing capability during the bone healing process. Nevertheless, it still shows a relatively loose structure around R-Ti-TiO$_2$ (Figure 5e). This is strongly supported by the additional statistical analysis for the ROI (Figure 5(g)), where biological tissue with large surface area is obtained, indicating more cavities are detected from the biological tissue around the implant when compared with the R-Ti-TiO$_2$-SnO$_2$. In the case of the implants with SnO$_2$-TiO$_2$ bi-layered coating, they exhibit the densest structure with excellent biological
tissue-implant contact. The reason for this is attributed to the electrical bioactivity of the coating, which benefits not only the directly contacted tissue, but also the surrounding tissues due to the effect of electrical field.

Figure 6 Schematic diagram for the stress distribution at the interface between bone and implants along the radial direction.

Apparently, the structure of biological tissue around the placed implant after healing of 12 weeks depends on the hierarchical structure of the implant surface (Figure 5). This is in agreement with the result that the stress distribution within the bone tissue is related to the recruitment and activity of BMU.\textsuperscript{7,42} After the ingrowth of new bone into the micro scale gouges, the placed implant with surrounding bone tissue can be considered as a composite material, which significantly changes the stress distribution in the bonding area (Figure 6). During the
remodeling process in cortical bone, osteoclasts could be observed on the surface of an area with reduced stress, and osteoblasts could be found on the surface of an area with increased stress. If a material is with hierarchical bonding interface, the stress on the bone tissue side is decreased but with an increasing trend toward the interface to implant. The decreased stress could promote osteoclast to resorb bone along certain direction, while the increase of stress could stimulate osteoblast to aid remodeling at the interface. Thus, more cavities but better bone-biological contact were observed around the R-Ti and R-Ti-TiO₂ when compared with the smooth group.

Because of the existence of artifacts, soft tissue and mineral bone are hard to be distinguished by the Micro-CT analysis. To further support our point about the BMU coupling, histological morphometry of the Van Gieson (VG) stained bone tissue within 500 µm to the surface of implant has been investigated (Figure 7). Apparently, the cavities containing osteoclast and osteoblast can be clearly observed in the magnified histological morphology around implants. As the functional unit for bone remodeling, BMUs is considered as the most obvious agent to adjust and reveal the bone healing situation around the implant surface in micro scale. Disturbances of any stimulation that shift the equilibrium of BMUs would lead to the change in bone remodeling around implants. Herein, the change in size of cavity containing BMU is mainly attributed to two factors of the as-formed implants, the bioactivity of coating and the micro gouge structure.
Figure 7 Histological analysis of the bone around the implants after surgery for 12 weeks: a) gross morphologies of the VG stained bone tissue around implants, the representative histological morphology of b) Ti, c) Ti-TiO₂, d) Ti-TiO₂-SnO₂, e) R-Ti, f) R-Ti-TiO₂, g) R-Ti-TiO₂-SnO₂, and h) the histomorphometric results of mineralized bone, soft tissue and gap in the interested zoon. (yellow arrow) osteoblasts; (green arrow) osteoclasts; (yellow ring) osteon; (MB) mineralized bone. *p < 0.05 compared to the Ti implant, #p < 0.05.
compared to the Ti-TiO$_2$, $p < 0.05$ compared to the Ti-TiO$_2$-SnO$_2$, $\&p < 0.05$ compared to the R-Ti, $%p < 0.05$

compared to the R-Ti-TiO$_2$.

As for the smooth surface group, the behavior of BMUs is dominated by the bioactivity of the implant surface. Generally, the equilibrium of BMUs around implants shifts towards bone resorption after implantation, due to the decrease of stress stimulation to bone tissue caused by the stress shielding effect. Regarding the Ti implant, the surrounding tissue normally shows osteoporosis due to the bio-inertness of pure Ti (Figure 7(b)), which is unable to promote osteoblastic functions (such as proliferation, migration, differentiation, secretion of matrix proteins, and its mineralization) to rebalance the equilibrium of BMUs. $^{50}$

In terms of Ti-TiO$_2$, the MAO coating with porous surface structure in sub-micro scale can enhance the proliferation and differentiation of osteoblasts. $^{51}$ Meanwhile, the TiO$_2$ coating with negative surface charges can attract Ca$^{2+}$ and proteins absorption. $^{52}$ They all shift the equilibrium of BMUs around the implant surface towards the bone generation, playing a positive role in osseointegration. Thus, a direct bone-implant contact has been observed around the implant surface near the marrow cavity (Figure 7(c)). However, because of the relatively weak Ca$^{2+}$ attraction for TiO$_2$ surface and the indirect contact of the surface with both the cell and proteins from medullary cavity fluid, some surface of the Ti-TiO$_2$ is still partially separated by gaps or soft tissue near the implantation site. It should be noticed that cavities with osteoclast cell have also been observed in the indirectly contacted bone tissue around Ti-TiO$_2$ (Figure 7(c)), indicating that the positive effect of the MAO coating on BMUs for bone generation is only limited in the directly contacted area.
Though the Ti-TiO$_2$-SnO$_2$ shows similar surface roughness with Ti-TiO$_2$, the equilibrium of BMUs around it shifts significantly towards the generation of new bone. This phenomenon is obviously dominated by the electrical bioactivity of the bi-layered coating rather than the nano-topography of the SnO$_2$ surface, as the densely packed SnO$_2$ nanorods would not benefit focal adhesion assembly of cells.\textsuperscript{30,53,54} Specifically, transient receptor potential melastatin 7 (TRPM7) protein is one of the signaling pathways on plasma membranes, exhibiting spontaneously activated divalent cation (Ca$^{2+}$, Mg$^{2+}$) entry, which is important for osteoblast differentiation.\textsuperscript{55,56} Because the surface of SnO$_2$-TiO$_2$ heterojunction with negative zeta potential can attract Ca$^{2+}$ and Mg$^{2+}$ absorption,\textsuperscript{30} the functional activity of TRPM7 would be ensured under the culture conditions with high intracellular Ca$^{2+}$ or Mg$^{2+}$ concentrations, benefiting the osteoblast differentiation of mesenchymal stem cells around implant.\textsuperscript{57,58} Therefore, a cement line interface has been observed on the surface Ti-TiO$_2$-SnO$_2$ (Figure 7(d)). Meanwhile, larger amount of osteoblast cells has been proliferated in the cavities around Ti-TiO$_2$-SnO$_2$ when compared with the others.

Regarding to the rough implants with micro gouge structure, it is obvious that the osseointegration has improved when compared with the smooth surface with the same modified coating (Figure 7). This is attributed to the changes in the absorption of cells and proteins and the topographic cue for the surrounding tissue based on the implant structure. Firstly, the migration and proliferation of osteoblast or stem cell and absorption of matrix proteins has been accelerated by the gouges surface structure because of its storage ability for the medullar cavity liquid. Secondly, the space provided by surface gouges changes the topographic cue to the surrounding
bone tissue. The micro gouges are very similar to the structure of proceed osteonal tunneling with BMUs, which would be quickly refilled by osteoblast. Thus, the equilibrium of BMUs around the rough implants with micro gouges shifts towards the bone formation.

Associated with the electrical bioactivity of SnO$_2$-TiO$_2$ coating and the surface gouge structure, the attraction of Mg$^{2+}$ and Ca$^{2+}$ by the built-in electrical field would be significantly enhanced by the superposition of the electrical field based on the micro gouges structure. Thus, more Mg$^{2+}$ and Ca$^{2+}$ would enrich around the Ti-TiO$_2$-SnO$_2$ surface. It could ensure the functional activity of TRPM7, showing excellent osseointegration around the implant (Figure 7(g)).

![Biomechanical results of the implants after surgery for 12 weeks](image)

**Figure 8** Biomechanical results of the implants after surgery for 12 weeks: a) the typical displacement curves of the implants during the push-out process, b) the push-out force of the implants with different surface structures. *p < 0.05 compared to the Ti implant, #p < 0.05 compared to the Ti-TiO$_2$, ^p < 0.05 compared to the Ti-TiO$_2$-SnO$_2$, &p < 0.05 compared to the R-Ti, %p < 0.05 compared to the R-Ti-TiO$_2$.

To evaluate the long-term bonding between the developed implant and bone tissue, the
push-out forces for the implants after healing of 12 weeks have been studied (Figure 8). As expected, both the electrically bioactive coating and the gouges structure surface exhibit an increase in the push-out force. In the case of the smooth implant group, the enhancement in the push-out force is dominated by the bioactivity of the implant surface. Obviously, the push-out force of the implant with SnO$_2$-TiO$_2$ is significantly improved to 239 N, which is over 5 times that of the pure Ti (50 N) ($p<0.05$). As for the rough implants with micro gouges, though it has less amount of remodeled bone around the implants, they exhibit much higher push-out force than the smooth ones (Figure 8). In consistent with our previous work,\textsuperscript{14} no matter how the bone-implant contact is, the push-out force for R-Ti and R-Ti-TiO$_2$ is similar. The reason for this could be attributed to the meshed bone-implant interface, which changed the failure mode of the implant when compared with the smooth ones. Interestingly, the push-out force of R-Ti-TiO$_2$-SnO$_2$ is further increased to 289 N, which is much stronger than that of R-Ti-TiO$_2$ and R-Ti. This supports our analysis that the electrical bioactivity benefits the osteoblastic function, leading to increased mineralization of extra-cellular matrix (ECM) around the developed implant to transmit load efficiently.
Figure 9 Surface morphologies of the pushed-out implants after healing of 12 weeks: a) gross images of the pushed-out implants, b) SEM images of the pushed-out implant surfaces with biological tissue at the cortical bone area, magnified SEM morphologies of the implant surface c) Ti, d) Ti-TiO$_2$, e) Ti-TiO$_2$-SnO$_2$, f) R-Ti, g) R-Ti-TiO$_2$, h) R-Ti-TiO$_2$-SnO$_2$.

To confirm the failure mode of the implants, representative SEM images of the pushed-out implant in the cortical regions are investigated together with EDS. Clearly, larger amount of biological tissue with meshed structure is observed on the rough implant surfaces compared to the smooth ones (Figure 9). As for the smooth group, pure Ti implant is partially covered by soft tissue, leading to poor contact with surrounding bone tissue, while some deposition with the
shape of distorted sphere in multi-flakes (Ca 14.1 wt. % and P 1.4 wt. %) have been observed on the Ti-TiO$_2$ surface because of its bioactivity. As expected, a large amount of remnants bone (Ca 78.5 wt. % and P 12.2 wt. %) and sphere-like deposition (Ca 27.2 wt. % and P 6.1 wt. %) have been observed on the surface of Ti-TiO$_2$-SnO$_2$. The above evidence directly supports our analysis that the electrically bioactive coating can significantly improve the mineralization of the remodeled bone tissue through the attraction of Mg$^{2+}$ and Ca$^{2+}$, providing ions signal via the pathway of TRM7 on the plasma membrane to accelerate the osteoblastic functions. Further analysis on the fracture morphology in the cortical bone area of the implant shows that some part of the coating on the Ti-TiO$_2$-SnO$_2$ has been pulled out with the bone tissue (Ti 78.8 wt. % and C 8.8 wt. %) (Figure S5), indicating the synostosis in the cortical region. As for the rough group, the micro gouges on the R-Ti-TiO$_2$-SnO$_2$ surface around the cortical bone side are almost fully filled by dense mineral bone, and fracture mainly occurs at the bone side with large amount of Ca, P and Mg enriched sphere-like depositions (Figure 9). On the contrary, smaller amount of Ca, P and Mg enriched sphere-like depositions has been observed on R-Ti-TiO$_2$. This result is in agreement with Couchoureel’s suggestion that the culture conditions with low extracellular Mg$^{2+}$ and Ca$^{2+}$ concentrations promotes gene expression of collagen type I alpha 1, resulting in reduced mineralization of ECM because of the abnormal ratio of matrix protein. 59 This further supports our analysis that the electrical bioactivity provided by SnO$_2$-TiO$_2$ hetero-junction would benefit the mineralization of the indirect contact bone tissue around the implant, resulting in a significant improvement in osseointegration of the developed implant.

Recently many strategies have been developed to improve the osseointegration of Ti implant.
Compared with dense Ti implant, the scaffold Ti implant shows obviously enhanced push-out force thanks to the three-dimensional inter-locking effect for the new bone which grows into the holes after healing.\textsuperscript{10,60-63} Similar to the scaffold Ti implant, in this work, regenerated bone tissue also meshed with the rough implant in the gouge areas. While, since the fixed porosity of the rough implants limits the ingrowth of bone tissue, the further enhancement in push-out force of R-Ti-TiO\textsubscript{2}-SnO\textsubscript{2} is attributed to the increased mineralization of ECM around the implant with synostosis. Comparing the push-out stress with the literature values (seeing in supporting information Table S2), it suggests that the R-Ti-TiO\textsubscript{2}-SnO\textsubscript{2} shows the most improved performance, even better than that of surface chemically modified Ti scaffold. Taking the results together, the R-Ti-TiO\textsubscript{2}-SnO\textsubscript{2} with the synergistic effects of both electrical bioactivity and hierarchical surface structure has been demonstrated as an efficient approach to enhance osseointegration.

CONCLUSION

Hierarchically porous surface with SnO\textsubscript{2}-TiO\textsubscript{2} heterojunction has been fabricated on Ti implant. The significantly improved osseointegration is attributed to electrical bioactivity and hierarchical surface structure of the developed implant. The electrical bioactivity rendered by the bi-layered SnO\textsubscript{2}-TiO\textsubscript{2} coating on the implant benefits not only the contacted biological tissue but also the indirectly contacted one thanks to the generation of electrical signal. It improves the osteoblastic function of BMUs, leading to increased mineralization of ECM around the implant with synostosis. Thanks to the topographic cue from the hierarchically porous surface, the newly
formed bone tissue grows into the micro gouges of rough implant, exhibiting meshed bone-implant interface. Meanwhile, the osteoblastic function of BMUs is improved compared to the smooth ones, because the space provided by gouges can act as a storage of medullar cavity liquid, promoting the absorption of matrix proteins and attachment of cells. Benefiting from the superposition of the built-in electrical field provided by heterojunction on the hierarchically porous surface, the mineralization of the remodeled bone around the developed Ti implant is further enhanced, exhibiting excellent \textit{in vivo} performance. Therefore, the concept of hierarchically structured Ti implant with electrically bioactive surface could be a promising approach for developing the next-generation of load-bearing Ti implants, since it benefits from both electric and topographic cues to the living bone.

**EXPERIMENTAL SECTION**

**Surface modification.** The medical Ti rods with the size of $\Phi 2 \times L 6 \text{ mm}^3$ (Grade II, Baoji Haibao special metal materials Co., China) were used as Ti implants for the surface modification and animal surgery. Firstly, the rods were ground with 1000# abrasive paper, ultrasonically washed with acetone, ethanol and distilled water. The micro scale gouges were prepared on Ti implant surface via microarc oxidation (MAO) in an electrolyte containing $\text{NaNO}_3$ (0.1 M·L$^{-1}$) and $\text{NaOH}$ (0.25 M·L$^{-1}$) at 280 V for 2 min, then acidly washed in 48 wt.% $\text{H}_2\text{SO}_4$ at 80 °C for 2 h. To fabricate sub-micro scale porous coating on Ti, the implants were microarc oxidized in an electrolyte containing $\text{EDTA-2Na}$ (0.04 M·L$^{-1}$) and $\text{NaOH}$ (0.175 M·L$^{-1}$) at 450 V for 5 min. Next, the microarc oxidized implants were hung in a PTFE cup but soaked with 40 mL bulk
solution (distilled water 30 mL and ethanol 10 mL) containing 0.7 g of NaOH and 0.5 g of SnCl$_4$$ \cdot $5H$_2$O. Then, the steel vessel containing the PTFE cup were treated at 200 °C for 24 h. The surface modified implants were labelled according to the surface structure (Table S1).

**Surface characterization.** Surface morphology of the implants was observed by scanning electron microscopy (SEM, Helios Nanolab 600i, FEI Co., USA). The elemental composition of the surface with different features was investigated by an energy dispersive X-ray spectrometer (EDAX, USA) equipped with the SEM system. X-ray diffraction (XRD, D/max-gB, Japan) and Raman spectroscopy (Raman, Jobin Yvon, France) were used to analyze the phase composition of the smooth and rough implants, respectively. The phase and elemental composition of the nanorod formed on R-Ti-TiO$_2$-SnO$_2$ surface was further analyzed by transmission electron microscopy (TEM, Tecnai G2F30, FEI Co., USA) instrument via high resolution TEM and EDS. Reflectance spectra from 900-200 nm were recorded via UV-vis spectrophotometer (UV-2600, Shimadzu, Japan) to calculate the band gap for the semi-conductor layer on Ti-TiO$_2$, Ti-SnO$_2$ and Ti-TiO$_2$-SnO$_2$. The LSV curves of the samples were scanned from 0 V to 3 V versus SCE (saturated calomel reference electrode) by electrochemical workstation (CHI760E, Shanghai Chenhua Instrument, China), and 0.5 M Na$_2$SO$_4$ was used as the electrolyte.

**In vivo Experiments.** All the animal experiments were approved by the animal care and experiment committee of Xi’an Jiaotong University College of Medicine complied with the approved guidelines. The detailed animal experimental methods have been reported in our previous works.$^{14,30,50}$ Twelve New Zealand rabbits (2.5–3 kg for each) were used in this work. During the surgery, three holes (Φ 2 × L 6 mm$^3$) were drilled on each tibia of rabbit. And the Ti,
Ti-TiO₂ and Ti-TiO₂-SnO₂ implants were placed on the left leg, while the R-Ti, R-Ti-TiO₂ and R-Ti-TiO₂-SnO₂ were placed on the right leg (Figure S6).

After healing of 12 weeks, the rabbits were sacrificed to investigate the osseointegration of implants with different surface structures. X-ray 3D imaging system (Y. Cheetah, YXLON International GmbH, Germany) was used to rebuild the biological tissue around the implants in the region of interest (ROI) (Φ3 × L6 mm³) with an isotropic resolution of 8 µm. For morphometric measurement in ROI, the biological tissue volume (BV), total volume without the implant (TV) and biological tissue surface area (BS) were analyzed by VG Studio 2.1V. The Van Gieson (VG) stained transverse histological sections were observed by OLYMPUS microscope (CXX41, OLYMPUS, Japan) with a normal light source. The histomorphometrical measurement of the bone tissue with a distance of 500 µm to the cylindrical surface of implant was analyzed by ImageJ (Figure S7). The push-out force of the placed implants was measured by a universal testing machine (Instron-1186, Instron Co., USA).

**Statistical Analysis.** For the biomechanical test, six rabbits were used (n=6). Regard to each of the histological and micro-CT analysis, three rabbits were used (n=3). The student analysis of variance was used to calculate the statistical significance of difference by IBM SPSS statistical software package. The p values < 0.05 were considered statistically significant difference.

**ASSOCIATED CONTENT**

**Supporting Information.** The Supporting Information is available free of charge on the ACS Publications website. EDS analysis of R-Ti at the gouge area (Figure S1), SEM
morphology of the R-Ti-TiO$_2$-SnO$_2$ (Figure S2), weight of the modified Ti implants with
different surface structure (Figure S3), Raman spectra of Ti-TiO$_2$ and Ti-TiO$_2$-SnO$_2$ (Figure S4),
EDS analysis of the pushed-out Ti-TiO$_2$-SnO$_2$ in cortical bone region (Figure S5), X-ray
radiographs of the tibia with placed implants (Figure S6), and schematic diagram for the
histological morphometry of the VG stained sections (Figure S7); sample code based on the
structure of implants (Table S1), and comparison of push-out test results of the Ti implant
fabricated by different modified strategies (Table S2) have been used as supporting information
in this work.

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Notes

The authors declare that there is no conflict of interest.

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